Notice of Allowability	Application No.	Applicant(s)
	10/535,450	SATOSHI TANDA
	Examiner	Art Unit
	Felisa C. Hiteshew	1722
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT I of the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED in 5) or other appropriate commu RIGHTS. This application is si	this application. If not included
1. This communication is responsive to <u>July 11, 2007</u> .		
2. The allowed claim(s) is/are <u>1-8</u> .		
 3. Acknowledgment is made of a claim for foreign priority to a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 3. Note that the copies of the priority documents	ve been received. ve been received in Application	n No
International Bureau (PCT Rule 17.2(a)). * Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	" of this communication to file MENT of this application.	a reply complying with the requirements
4. A SUBSTITUTE OATH OR DECLARATION must be submined informal patent application (PTO-152) which given	mitted. Note the attached EXA ves reason(s) why the oath or	MINER'S AMENDMENT or NOTICE OF declaration is deficient.
5. CORRECTED DRAWINGS (as "replacement sheets") mu	ust be submitted.	
(a) including changes required by the Notice of Draftsper		(PTO-948) attached
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examine Paper No./Mail Date	r's Amendment / Comment or	in the Office action of
Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	1.84(c)) should be written on th the header according to 37 CFF	e drawings in the front (not the back) of R 1.121(d).
 DEPOSIT OF and/or INFORMATION about the dep- attached Examiner's comment regarding REQUIREMENT 	OSIT OF BIOLOGICAL MATE FOR THE DEPOSIT OF BIO	RIAL must be submitted. Note the LOGICAL MATERIAL.
Attachment(s) 1. Notice of References Cited (PTO-892)	5. ☐ Notice of Info	ormal Patent Application
2. Notice of Draftperson's Patent Drawing Review (PTO-948)		mmary (PTO-413),
3. Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date	Paper No./N 7. ☐ Examiner's A	Mail Date Amendment/Comment
Examiner's Comment Regarding Requirement for Deposit of Biological Material		Statement of Reasons for Allowance
	9.	Felisa C. Hiteshew Primary Examiner Art Unit: 1722

Application/Control Number: 10/535,450

Art Unit: 1722

DETAILED ACTION

Page 2

Allowable Subject Matter

- 1. Claims 1-8 are allowed.
- 2. The following is an examiner's statement of reasons for allowance: The most relevant prior art of reference was that which was submitted by the applicants. However, it does not teach nor fairly suggest singularly or in any combination thereof a transition-metal charlcogenide crystal having a topological configuration/structure. A micro-droplet of a chalcogen element such as S, Se or Te, is condensed and circulated in suspended form in an atmosphere containing a Group IVb, Vb or VI transition metal element, such as Nb, Ta, Zr, Ti, Hf or W, together with the chalcogen element. Then, micro-whiskers of a transition metal chalcogen-element micro-droplet by the action of a surface tension of the micro-droplet, and grown as a loop-shaped crystal would around the surface of the micro-droplet to obtain a loop-shaped crystal having a twist of O, π or 2π , wherein the crystal has a ribbon-like open or closed loop configuration. The transition-metal chalcogenide crystal with the topological look-shaped microstructure can exhibit original properties peculiar to each transition-metal chalcogenide, and has multiple applicabilities.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the

Art Unit: 1722

examiner should be directed to Felisa Hiteshew whose telephone number is (571) 272-1463. The examiner can normally be reached on Mondays through Thursday from 5:30 AM to 4:00 PM with Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Yogendra Gupta, can be reached on (571) 272-1316. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-1463.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system. see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866- 217-9197 (toll-free).

FELISA HITESHEW PRIMARY EXAMINER

Aum